IN THE CLAIMS:

The following is a complete listing of the pending claims:

Claims 1-5. (cancelled)

- 6. (currently amended) A stacked inductor comprising:
- a semiconductor substrate;
- a plurality of conductive layers formed on the substrate, the plurality of conductive layers being arranged from a first conductive layer closest to the substrate to a last conductive layer furthest from the substrate; and

a plurality of conductive spirals corresponding to the plurality of conductive layers such that a first spiral is formed in the corresponding first conductive layer, a second spiral is formed in the corresponding second conductive layer, and so on, wherein each spiral includes at least two concentric turns coiled from a first end at an outer radius of the spiral to a second end at an inner radius of the spiral; wherein the first end of the first spiral forms a first port for the inductor, a second end of the first spiral couples through a first via to the second end of the second spiral, the first end of the second spiral couples though a second via to the first end of the third spiral, and so on such that the a selected second end of the next-to-last spiral couples through a last via to a corresponding the second end of the last spiral, the remaining first end of the last spiral forming a second port for the inductor.

7. (currently amended) The stacked inductor of Claim 6, wherein each turn of each spiral comprises five or more linear segments further comprising a third spiral

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inductor having a first end at an outer radius of said spiral and a second end at an inner radius of said spiral on a third layer of said substrate, wherein said second end of said second spiral-inductor electrically coupled to said first end of said third spiral inductor.

- 8. (currently amended) The stacked inductor of Claim 6, wherein said first and second spiral inductors each spiral has a have thickness of between 1 and to 4 µm.
- 9. (currently amended) The stacked inductor of Claim 6, wherein said first and second cach spiral inductors comprise comprises a conductive metal taken from the group consisting of Cu, Al and alloys thereof.
- 10. (currently amended) The stacked inductor of Claim 7, wherein the number of linear segments equals eight A stacked inductor comprising:

a substrate; and

a plurality of planor spiral shaped inductors having a first end and a second end, each planer spiral shaped inductor disposed on a different layer of said substrate,

a first end of each of said planer spiral shaped inductors electrically coupled to a second of another planer spiral shaped inductors disposed on an adjacent layer.

11. (currently amended) The stacked inductor of Claim 6 10, wherein the first port is coupled to a power supply said plurality of planer spiral shaped industors comprises spiral inductors formed into concentric shapes of at least two turns, wherein each turn includes-at-least-five straight segments.

Claims 12 - 16. (cancelled)

- 17. (new) The stacked inductor of Claim 6, wherein the selected end of the next-to-last spiral is the second end, the corresponding end of the last spiral thereby being also being the second end.
- 18. (new) The stacked inductor of Claim 6, wherein the selected end of the next-to-last spiral is the first end, the corresponding end of the last spiral thereby being also being the first end.